

Docket No.: 4425-090

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PATENT

IN THE UNITED STATES PATENT AND FRADEMARK OFFICE

In re Application of

TECHNOLOGY CENTER PROPERTY PROCEDURE

RESPONSE UNDER 37 CFR 1.116

Pei-Ren JENG

U.S. Patent Application No. 09/729,833

Confirmation No. 5660

Group Art Unit: 2823

Filed: December 6, 2000

Examiner: Hsien Lee

For:

METHOD FOR PATTERNING A DUAL DAMASCENE WITH RETROGRADE

IMPLANTATION

REQUEST FOR RECONSIDERATION

Commissioner for Patents P.O. Box 1450 Alexandria VA 22313-1450

Sir:

This paper is submitted in reply to the Office Action mailed *July 25, 2003*, which was made Final. Reconsideration and allowance of the subject application in view of the following remarks is respectfully requested.